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(54) Method for etching half-tone silver halide images and silver halide photosensitive material for half-tone image reproduction.

(57) A black and white silver halide photosensitive material for contact copying of dot (or line) images comprises a highchloride fine-grain silver halide emulsion reactively associated with a compound selected from the group of thiazolium salt compounds, thiazole compounds and pyrazole compounds. Said compounds are preferably added to the silver halide emulsion in combination with a mercaptotetrazole compound. The photosensitive material allows, during the photomechanical etching process, a significant reduction in the area of the dots without causing a significant reduction of small dots.



EUROPEAN SEARCH REPORT

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DE-A-3 231 820 (FUJI PHOTO FILM CO.) * Page 4, line 4 - page 5, line 28; page 8, lines 14-28; example 1 * & GB-A-2 108 693 (Cat. D) TECHNICAL FIELDS SEARCHED (Int. CL4) G 03 C	Category	Citation of document with indicati of relevant passages	on, where appropriate,	Relevant to claim	CLASSIFICATION OF THE APPLICATION (Int. Cl. 4)	
G 03 C	X	* Page 4, line 4 - page page 8, lines 14-28; ex	e 5, line 28; kample 1 * &		G 03 C 1/06	
					TECHNICAL FIELD\$ SEARCHED (Int. CL4)	
The present search report has been drawn up for all claims	THE HAGUE			MARKI	Examiner OWSKT	
Place of search Date of completion of the search Examiner	CATEGORY OF CITED DOCUMENTS X: particularly relevant if taken alone Y: particularly relevant if combined with another document of the same category A: technological background O: non-written disclosure P: intermediate document		T: theory or principle E: earlier patent dec after the filing da D: document cited in L: document cited fo	T: theory or principle underlying the invention E: earlier patent document, but published on, or after the filing date D: document cited in the application L: document cited for other reasons &: member of the same patent family, corresponding		